In a combined quasi in situ scanning force microscopy study we close trace the alignment process of thin polymer films of poly(styrene)-b-poly(2-vinylpyridine)-b-poly(tert-butyl methacrylate) triblock terpolymer exposed to a high electric in-plane field and solvent vapor. Our experiments show that in this triblock terpolymer a perforated lamella structure forms the basis for the core–shell cylindrical structure. Further we observe a hexagonal superstructure during the alignment process that occurs with solvent vapor annealing in the presence of a high electric field (6–15 V μm⁻¹). The electric field induced reorientation includes a rupture-and-growth mechanism and the rotation of the hexagonal lattice. We reconstruct the 3D-structure of the aligned microdomains with quasi in situ SFM nanotomography. The gained 3D reconstructions lead to a detailed understanding of the polymer film behavior in the border region between perforated lamella and the cylindrical phase. Combining time-resolved SFM datasets with 3D reconstructions, we present a model for the rearrangement of the polymer cylinders on the basis of a hexagonally perforated lamella. One-dimensionally aligned core–shell cylinders could form the basis for electrically isolated nanowires once the cylinder core is metalized.

**Introduction**

Molecular self-assembly of block copolymers in thin films is a promising method for the structuring of surfaces on the nanometre scale. The obtained order is usually limited to microdomains in the size of a few nanometres. To obtain a macroscopic order or even a single domain structure, external fields can be applied to the polymer film.1,23 Besides gradient fields (e.g. shear fields,1,3 temperature gradients1,24–26), the use of electric fields for the alignment of block copolymer microdomains has been shown in the melt or in concentrated solutions.27–33

For the reorientation mechanism in block copolymer melt thin films, Amundson postulated two main orientation mechanisms: the movement and elimination of defects and the electric field induced selective disordering.24 Nucleation and growth as well as grain rotation are dominant in concentrated block copolymer solutions exposed to a high electric field in bulk samples. In weakly phase separated systems, microdomains aligned parallel to the electric field vector grow at the expense of those aligned parallel to the electrodes. The rotation of unfavorably oriented grains by defect movement usually occurs in highly phase separated block copolymer solutions.24 In thin films of a block copolymer swollen in solvent vapor, rough alignment parallel to the electric field vector was achieved by rupture and reformation. Improvement of the order in a structure that is almost perfectly aligned parallel to the electric field lines proceeds via movement and annihilation of defects.25 Still, in thin films also more complex alignment mechanisms can be observed. Olszowka observed that with successive E-field application of a lamella forming block copolymer, first ringlike defects (tori-defects) emerge while defect configurations with interrupted continuity of a lamella domain (open-end defects) are annihilated continuously.26

In a thin film of a cylinder forming diblock copolymer melt with film thickness equal to the cylinder spacing in the bulk, a perforated lamella (PL) phase is formed. Ly et al. have shown by dynamic density functional theory simulations that by applying an electric field, this PL transforms to cylinders. Here, the arms of 3-fold branching points that are not in the direction of the applied field vectors break. A transition state with insufficient annealing and/or E-field application results in a mixed morphology of PL and undulating cylinders.27

The alignment of cylinder forming polymers and its mechanism were studied using scattering methods and TEM cross-sections in thick films.28–30 In thin films below one micrometre film thickness, mainly the final aligned structure was studied.21,22 In simulations, spherical and bicontinuous intermediate structures were found during the alignment.23 In experiments, a spherical intermediate was verified while aligning...
a ~500 nm thick film. Still, there is no detailed understanding of the alignment mechanisms on the scale of individual cylinders to date. Furthermore, core–shell structures have not yet been studied in E-Field alignment experiments to the best of our knowledge. For an overview on block copolymer structures in thin films in general, see ref. 25.

3D imaging of various types of sample materials can be carried out based on non-destructive or destructive techniques. Non-damaging techniques are X-ray microscopy, transmission electron microscopy (TEM), atom probe field ion microscopy (APFIM), and focused-ion-beam (FIB) tomography. A recently published non-damaging depth-resolved imaging method is based on scanning force microscopy (SFM) and tip indentation mapping. Destructive methods are based on measuring ultra-thin layers of the sample material e.g. by combining the ultramicrotome technique with scanning force microscopy (SFM) or with scanning electron microscopy (SEM).

Using common in situ methods that are based on electron microscopy like TEM or scanning electron microscopy (SEM) imaging combined with plasma etching, sensitive surfaces like polymer materials can be easily destroyed by the electron beam. The combination of ultramicrotomiting with SFM is limited to a step-size of at least 20 nm due to the ultramicrotome setup. The depth range of the SP-based method by Spitzner et al. is limited by the tip indentation (material dependent by the compliance of the material).

In contrast to the above mentioned techniques, with nanotomography as a SPM-based method, material properties can be mapped in 3D volume space. It combines well-established SFM surface characterization with suitable ablation techniques. Various SPM techniques and erosion methods like plasma etching, chemical wet etching or mechanical polishing can be combined.

The successive erosion of thin specimen layers followed by scanning each newly exposed surface leads to a series of topography and corresponding property maps which can be combined to a real space volume image of the sample. Performing nanotomography with a scanning force microscope (SFM), both the topography and the corresponding material maps are accessible using standard SFM modes like tapping-mode imaging. For example, the second flexural eigenmode of the cantilever can be used for phase imaging combined with wet chemical etching as the ablation method. Other techniques like HarmoniX or Peakforce QNM could also be used to perform nanotomography.

A suitable ablation method for sensitive polymer materials is low pressure (LP) plasma treatment. By adjusting process parameters like gas composition, process pressure, treatment time, and rf power, thin layers in the low nanometre regime can be removed in a precise and reproducible way without creating noteworthy thermal load or mechanical stress to the specimen. For a poly(styrene)-b-poly(2-vinylpyridine)-b-poly (tert-butyl methacrylate) triblock terpolymer (SVT) copolymer material like the one described in this paper, low pressure plasma was already successfully used for etching. Generally, the type of etching technique can be regarded as a key enabling technique for a successful nanotomographic examination, because it limits its practical application as a matter of principle, and more specifically, the accomplishable depth-resolution, quality and quantity of the acquired data.

In the setup described by Magerle and Konrad et al. plasma etching is performed ex situ in a system separated from the SFM. This leads to time-consuming measurement protocols for relocating the same sample spot and results in general low performance. Moreover it leads to principle problems of practicability and manageability. Known recipes to relocate to a specific sample spot are based on landmarks on the sample surface. They fail if the landmark vanishes or changes its shape due to the treatment effects. Moreover, taking large overview images in order to reposition the probe relative to the sample results in “stress” to the probe and hence reduced image quality. In order to overcome these problems and principle limitations of common in situ techniques, Hund et al. developed a quasi in situ scanning probe microscope which enables even harsh sample treatments like LP-plasma, solvent vapor treatments under high electric fields and other aggressive treatments inside the SFM which are normally not possible to apply while scanning like harsh chemical treatments. During sample treatment the probe is therefore spatially separated from the sample. After each SFM characterization the probe is macroscopically separated from the sample surface while the sample is stationary (see “lock mode”, ref. 59, p. 3). Hence, high position stability (sample/probe) is reached.

The quasi in situ SFM setups used in this paper to study the alignment of SVT polymer microdomains and to perform the nanotomographic examination utilize modified commercial SFMs (Dimension 3100 series from Veeco Instruments, Inc.) and specific process equipment. For solvent vapor annealing in the presence of a high electric field, the system is equipped with an automatically operated reaction chamber featuring automated opening, closing, and an active sealing. It turned out that for our sample treatments (flow-through) a hermetically sealed chamber is mandatory for successful and reproducible treatment steps. The details of the PC-controlled reaction chamber and a fully automated QIS-SFM system featuring a synchronization of data acquisition and sample treatment steps (including sample spot tracking) are described elsewhere.

The outline of the paper is as follows: first we present the typical structures of poly(styrene)-b-poly(2-vinylpyridine)-b-poly (tert-butyl methacrylate) triblock terpolymer (SVT) before and after annealing in an electric field and solvent vapor (SEM images). We compare the results with nanotomographic reconstructions of the aligned SVT. To investigate the alignment mechanism, we discuss results of time-resolved quasi in situ SFM data. Finally, we suggest an alignment model with cylinders based on a perforated lamella structure.

**Experimental**

**Polymer**

The studied cylinder forming ABC triblock terpolymer consists of 16 wt% polystyrene (PS), 21 wt% poly(2-vinylpyridine) (P2VP) and 63 wt% poly(tert-butyl methacrylate) (P(BMA)) with a total weight-average molecular weight $M_w = 140$ kg mol$^{-1}$ (denoted as $S_{16}V_{21}T_{63}$); subscripts denote the weight percentage of the respective block while the superscript names the weight-average.
molar mass in kg mol\(^{-1}\)). The polymer was synthesized by sequential living anionic polymerization as described elsewhere.\(^62\) Gel permeation chromatography of the block terpolymer yields a polydispersity of \(M_p/M_n = 1.03\). In the bulk, the material has a structure of hexagonally packed core–shell cylinders embedded within the PrBMA matrix material. The characteristic spacing for S\(_{16}V_{21}T_{63}\) cylinders is 71 ± 3 nm in the bulk (from SAXS measurements) and 66 ± 3 nm in thin films (from SFM measurements).

**Polymer films**

Films with a thickness of 67 ± 2 nm were spin cast from chloroform solutions onto glass substrates, ensuring that only one cylindrical layer is found in the films. These films were pre-annealed in saturated CHCl\(_3\) vapor at room temperature for 9.5 min resulting in the starting cylinder morphology for our experiments. The structure consists, according to previous studies, of a thin brush layer where the P2VP block is attached to the surface.\(^63\) Above this brush layer, core–shell-structures of PS (core) and P2VP (shell) are embedded in a matrix of PrBMA. The latter is aligned at the free surface because of the lowest surface energy.\(^64\)

**Substrates**

For our experiments, we used glass substrates with evaporated gold electrodes of 28 nm height.\(^65\) The electrode distance was chosen as one specific value between 5 and 10 microns. The very large aspect ratio between electrode spacing and the electrode length (6 mm) allows applying a homogeneous electric field.\(^66\)

**SEM**

SEM images were taken using a Zeiss Leo Gemini instrument with a field emission cathode at a voltage of 0.5 kV. By the exposure to an electron beam in the SEM, the PrBMA block within the S\(_{16}V_{21}T_{63}\) was depolymerized and evaporated. As this block builds the matrix surrounding the PS–P2VP-core–shell-structures, matrix areas appear black in SEM images. No further staining of the films was necessary. From the order parameter derived from SEM measurements using gradient fields (the same technique like in ref. 65; not shown here), critical electric field strength for aligning the structures was derived as 4.1 V \(\mu\)m\(^{-1}\). To be sure an optimal alignment is reached during the annealing time; the experiments described in this paper were performed well above that critical value at 15 V \(\mu\)m\(^{-1}\) unless mentioned otherwise.

**QIS-SFM**

The quasi in situ setups utilize modified commercial Dimension\™ 3100 SFMs (all from Veeco Instruments Inc.). They are equipped with a NanoScope\® V controller and an XYZ closed-loop scanner (annealing experiments) and a NanoScope\® IV controller and an XY closed-loop scanner (nanotomographic experiments), respectively. For both, the original sample chuck was replaced by a special air bearing table holding a specific reactor chamber module.

For solvent vapor annealing in the presence of a high electric field the system is equipped with an automatic operated reaction chamber featuring automated opening, closing, and an active sealing of the cover against the reactor chamber. It turned out that for our sample treatments (flow-through), a hermetically sealed chamber is mandatory for successful and reproducible treatment steps. The details of the PC-controlled reaction chamber and a fully automated QIS-SFM system featuring a synchronization of data acquisition and sample treatment steps (including sample spot tracking) are described elsewhere.\(^64\)

For the nanotomographic experiments a plasma generation module (inductively coupled plasma source) was additionally installed. The system features an automatic tip/sample separation (movements of the z-stage in the mm range) with the help of a self-developed NanoScript™ application. Moreover, an automatic and triggered grounding of the sample during scanning was implemented. A detailed description of the setup is given elsewhere.\(^58\)–\(^60\) The experiments were performed using Si\(_3\)N\(_4\) cantilevers from Olympus (spring constant 35–60 N m\(^{-1}\); resonance frequency 280–340 kHz).

The scan area (3 \(\mu\)m \(\times\) 3 \(\mu\)m) was kept constant during the experiment. In a first post-processing step the remaining lateral offsets between successive SFM images were corrected by maximization of the cross-correlation between the images. We note that the used SFM is equipped with a state-of-the-art closed-loop scanner, which drastically reduces image distortions.

After registration, a smaller detail of each SFM image was cut out to provide a series of images taken at exactly the same spot of the sample. Further details on the measurements and data processing/evaluation can be found in the ESI\footref{ESI}.

**Results**

For our studies we use a poly(styrene)-b-poly(2-vinylpyridine)-b-poly(tert-butyl methacrylate) triblock terpolymer, further denoted as S\(_{16}V_{21}T_{63}\), like described previously.\(^56\),\(^62\),\(^63\),\(^67\),\(^68\) The subscript denotes the weight percentage of each component, and the superscript gives the overall molecular weight in kg mol\(^{-1}\).

Core–shell cylinders and hexagonally perforated core–shell lamellae of polystyrene (PS, core) and poly(2-vinylpyridine) (P2VP, shell) in a poly(tert-butyl methacrylate) (PrBMA) matrix were observed in thin films. The matrix covers the PS–P2VP structures. After spin-coating of a S\(_{16}V_{21}T_{63}\) film from chloroform solution onto silicon or glass, the structure equilibrated after 9.5 min of chloroform vapor annealing. The interaction parameters \(\chi\) between the individual homopolymer blocks and the solvent are \(\chi_{PS/CHCl_3} = 0.35\), \(\chi_{P2VP/CHCl_3} = 0.38\) and \(\chi_{PrBMA/CHCl_3} = 0.40\) like derived from the Hildebrand solubility parameters.\(^69\) As they do not deviate much from each other, the solvent is nearly unselective. For further details, see ESI\footref{ESI}.

In topographic SFM images (see Fig. S1, ESI\footref{ESI}) a mainly striped pattern is found.

Fig. 1a shows a SEM image of a S\(_{16}V_{21}T_{63}\) polymer film after 9.5 min chloroform annealing in which the top covering layer was removed (depolymerized and vaporized by the electron beam). Dark lines and spots can be observed between the gray areas.

Fig. 1b shows the polymer film after additional annealing in pure chloroform vapor in the presence of an electric field (6 V
To verify the composition of these bridges, we perform quasi in situ scanning force microscopy (QIS-SFM) nanotomography using low pressure plasma treatments (22 etching steps) of a $S_{16}V_{21}T_{63}$ film aligned using an in-plane electric field (15 V $\mu$m$^{-1}$, 5 h chloroform annealing, for details see Experimental section and ESI†).

The covering matrix of PrBMA can be easily removed because the tert-butyl group is very sensitive with respect to LP-plasma. Upon subsequent low pressure plasma treatments the weak ester linkages break and small species are vaporized.70

Fig. 2 shows 3D reconstructions of a $S_{16}V_{21}T_{63}$ polymer film sample at two spots. The topographic and the corresponding phase information (tapping-mode imaging, raw data 3 $\mu$m $\times$ 3 $\mu$m) are combined to 3D volume datasets. Red parts correspond to the core–shell structures while the matrix appears transparent. Because of the similar properties and because the PS phase is surrounded by P2VP it is not possible to distinguish the PS and P2VP phases while we can clearly discern the cylinders from the matrix. For a detailed explanation of the used data evaluation including the voxelization algorithm and the z-calibration, see the Experimental section, ref. 60 and ESI†.

In Fig. 2a, a regular network of nearly perfectly aligned cylinders is shown (arrows indicate direction of the electric field vector). In Fig. 2b PL domains can be clearly observed (marked by a yellow dashed ellipse). At some spots (examples marked by white circles) undulating cylinders are approaching each other or connect via thin bridges to form a PL structure. The matrix polymer between these cylinders forms perforations that are either spot-like or are formed by the connection of neighboring spots. This finding of spot-like and connected linear elongated perforations is very similar to the theoretical predictions of Ly et al.18 in which a HPL structure transforms to an aligned cylindrical one by applying an electric field in the lamellar plane.

These findings let us assume that an underlying perforated lamella structure forms the basis for the cylindrical structure here. This is supported by viewing the PL as parallel cylinders (C$_1$) containing a regular network of 3-fold branching points which are structural defects in the C$_1$ phase. Through an undulating film thickness, the PL can emerge out of a cylindrical phase in ABA triblock terpolymer thin films.71,72 The SEM images in Fig. 1 and the previously observed hexagonally perforated lamella in this polymer56,62,63,67,68 confirm this assumption. Because of the structural similarity of the PL and C$_1$ phases and as there seems to be an equilibrium between cylinders and perforated lamellae or a perforated superstructure, we further refer to the general term core–shell structures even though we only talk about core–shell cylinders and perforated core–shell lamellae.

In order to study the process of orientation that leads to the aligned structures (Fig. 1 and 2), we performed QIS-SFM experiments with an applied electric field of 15 V $\mu$m$^{-1}$ in the presence of chloroform vapor. It is important to mention that cylindrical and perforated structures under the covering PrBMA matrix can be observed in SFM topographic images after solvent annealing because of the slightly different drying rates of the blocks from solution.79

Fig. 3 shows the evolution of the pre-annealed structure (Fig. 3a) to an aligned structure (Fig. 3e) of a $S_{16}V_{21}T_{63}$ polymer thin film as a function of cumulative treatment time in

---

**Fig. 1** SEM images of a $S_{16}V_{21}T_{63}$ polymer film. (a) After annealing for 9.5 min in saturated chloroform vapor; (b) after additional 5 h annealing in saturated chloroform vapor in the presence of an electric field (6 V $\mu$m$^{-1}$, electric field vector direction is horizontal); (c) and (d) are the corresponding cutouts (cf. dashed areas in (a) and (b)). The indicated brighter and darker spots are hints to bridging areas. (a) and (b) are not taken at the same sample spot.

μm$^{-1}$, 5 h) at a different sample spot. Fig. 1c and d show corresponding cutouts (cf. dashed white areas in Fig. 1a and b). Dark spots and dark lines (Fig. 1c) which are aligned preferentially in the direction of the electric field vector (Fig. 1d) are clearly visible.

Because the PrBMA block in $S_{16}V_{21}T_{63}$ polymer was destroyed by the electron beam, we assign the dark areas to the matrix material. The remaining gray areas hence consist of brighter and darker spots that hint to bridging areas between the cylinder forming polymer blocks (marked by white ellipses in Fig. 1c and d).
breaks at the expense of the parallel one. Even with studying the bright areas in SFM topographic images, which correspond to the matrix between the cylinders and in the perforations, the orientation of the cylindrical structures (darker areas in SFM images) becomes visible as each cylinder is situated between two elongated perforations (bright lines).

After 11 minutes of E-field and solvent vapor annealing (Fig. 3e), the predominant orientation develops parallel to the electric field vector. Because of resolution issues (due to a fast dewetting of the film), in the following experiments, we use 67% saturated chloroform vapor to anneal the film (Fig. 4). After 6 min of treatment (E-field strength of 15 V μm⁻¹ and solvent vapor) a bright line that is aslant to the electric field vector is visible in the center of the image (a), highlighted with white ellipse. With further annealing, the angle between this line and the electric field vector decreases continuously (Fig. 4b and c).

After 49.5 min of annealing under an electric field, the bright line is oriented parallel to the electric field vector (Fig. 4d). As mentioned, the bright areas correspond to the P/BMA matrix filling the perforations in every layer of cylinders. As the elongated perforations rotate, cylinders situated next to the bright lines in SFM images align by some rotation mechanism as well.

**Discussion**

**Perforated superstructure**

In the following we propose an alignment mechanism of S₁₆V₂₁T₆₃ polymer films exposed to in-plane electric fields. Like recently simulated in the group of Zvelindovsky,¹⁸,⁷² the electric field induced transition from a perforated to a cylindrical structure in AB and ABA block copolymers proceeds through the combination of adjacent perforations. During the transition, the newly formed cylinders contain undulations resulting from former matrix branching points.

In a cylinder forming block copolymer, −1/2 disclinations can contain PL clusters that are metastable.⁷⁴ By solvent vapor annealing of such a film in the absence of an electric field, perforated lamella defects have lifetimes ranging from minutes to hours⁷⁵ and can also appear as nuclei for the formation of stable PL grains.⁶,⁷⁷ One polymer can establish stable PL and C₅ phases depending on the film thickness without a change of the surface fields.⁷²

Fig. 1 and 2 show a mixed morphology of PL and C₅ in S₁₆V₂₁T₆₃ polymer thin films before and after applying an electric field. Same as after solvent vapor annealing with no electric field applied, PL domains are apparently stable in the cylindrical phase. Undulations in the cylindrical domains also point to a tendency to form PL domains. This supports the assumption of a perforated superstructure. In Fig. 5, white lines connect the darkest spots in the SEM images from Fig. 1 before and after extensive annealing (a and b, respectively). A mainly hexagonal arrangement of the dark spots becomes obvious. Yellow and blue circles denote exceptions from the hexagonal arrangement. Here, perforations are arranged either in a pentagonal (yellow) or heptagonal (blue) shape. In a hexagonal lattice, such 5/7 defects are well known.⁸ They appear preferentially in the close vicinity to structural defects like disclinations and dislocations. The hexagonal superstructure for the polymer
film is also supported by the appearance of the PL phase. Our results for S$_{16}$V$_{21}$T$_{63}$ polymer thin films agree with similar calculations in ABA block copolymer thin films, where under certain parameters PL and C$_{t}$ domains coexist in a sample. This indicates a strong structural similarity and can be interpreted as the PS–P2VP cylinders are arranged in a pattern formed by the PL structure. Without electric field, there is no preferred direction in the structure (Fig. 5a). After extended application of an electric field (Fig. 5b), one of the three main directions of the surface lattice is nearly parallel to the electric field vector.

**Alignment model**

S$_{16}$V$_{21}$T$_{63}$ polymer cylinder alignment parallel to the electric field vector proceeds through two main mechanisms: rupture-and-reformation of cylinders (Fig. 3) and cylinder rotation (Fig. 4). The time scales of Fig. 3 and 4 are hardly comparable due to the different annealing conditions (67% vs. saturated chloroform vapor). In concentrated block copolymer solutions, Schmidt et al. showed experimentally and theoretically that solutions with the initial block copolymer orientation normal to the electric field vector preferentially reorient by the nucleation-and-growth mechanism. Grain rotation by defect movement and annihilation is preferred if the initial orientation is aslant to the direction of the electric field vector. Keeping in mind the assumption of a hexagonally perforated lamella as the superstructure of aligned and non-aligned S$_{16}$V$_{21}$T$_{63}$ core–shell cylinders (Fig. 5) and the different observed orientation mechanisms in Fig. 3 and 4, we present a model of the rearrangement of the cylinders with underlying perforated structure. This is schematically shown in Fig. 6. We assume that effects similar to the ones in concentrated solutions occur simultaneously. In the schematic 5/7 defects and their annihilation are not taken into account.

In Fig. 6a we show a perfect hexagonal arrangement of dark spots with most of them being connected randomly by black and red lines. The white area between these lines represents the cylinders of S$_{16}$V$_{21}$T$_{63}$ while the black and red parts denote the...
PrBMA-filled perforations between the cylinders. The figure shows a similar structure to the one depicted in Fig. 1c and 5a before E-field application. After inducing mobility (solvent vapor) and a directing force (electric field) to the sample, the structures start to align in a preferred direction. The intercylindrical PrBMA areas that are oriented nearly normal to the electric field vector break and reform in nearby positions where they are almost parallel to the electric field vector, keeping the hexagonal lattice. Simultaneously, the lattice starts to rotate. Additionally, defects in the hexagonal structure might be annihilated (not shown here). A more detailed characterization of defect behavior is beyond the scope of this paper and is subject to further research. In Fig. 6b, blue lines show the PrBMA parts newly formed from the red drawn matrix parts in Fig. 6a. With further annealing in the presence of an electric field, lattice rotation and rupture processes continue to form the final aligned structure shown in Fig. 6c. In this figure, every cylinder is oriented parallel to the electric field vector. Like before the application of an electric field and solvent vapor, some PL domains persist. The structure is similar to the one shown in Fig. 1d and 5b.

Hexagonal structure during solvent vapor annealing with applied electric field

To prove the existence of a hexagonal structure during solvent vapor annealing, we show QIS-SFM topographic images of a specific surface spot after 34.5 (a) and 49.5 (b) min annealing in vapor annealing, we show QIS-SFM topographic images of domains persist. The structure is similar to the one shown in Fig. 6c. In this figure, every cylinder is oriented parallel to the electric field vector. Like before the application of an electric field and solvent vapor, some PL domains persist. The structure is similar to the one shown in Fig. 1d and 5b.

Conclusions

In this study, we extensively used the quasi in situ technique for both the time-resolved examination of a cylindrical block copolymer and the nanotomographic characterization of the gained structure. It turned out that the quasi in situ SFM technique presented in this study is very powerful and has a large potential which goes significantly beyond the problems studied here. The possibility of imaging the same spot of the sample allows to closely follow any sample changes occurring as a consequence of certain treatments, which may require a hermetically sealed reactor chamber and/or which cannot be applied in the presence of the tip. This may involve LP-plasma treatments as well as the exposure to solvent vapors in the presence of high electric fields as shown in the paper or other treatments e.g. aggressive chemicals and high electromagnetic fields.

Acknowledgements

We thank Andrei V. Zvelindovskiy for fruitful discussions and Andreas Fery and Larisa Tsarkova for support. Financial support by the Deutsche Forschungsgemeinschaft (DFG) and the European Union in the framework of the ERA-NanoSci²-project MEMORY is gratefully acknowledged. Clemens Liedel thanks the ENB Macromolecular Science and acknowledges the Fonds der Chemischen Industrie for financial support by a Chemiefonds Fellowship.

Notes and references
